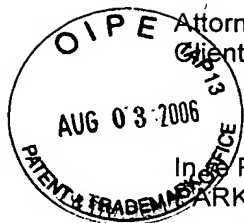


TFW



Attorney Docket: 061063-0316598
Client Reference: OSP-18418

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor: PATENT APPLICATION of:
MARK ET AL.

Confirmation Number: 9014

Application No.: 10/540,992

Group Art Unit: 2812

Filed: June 5, 2006

Examiner: Unassigned

Title: CHEMICAL-MECHANICAL-POLISHING SLURRY COMPOSITION, METHOD FOR
PLANARIZING SURFACE OF SEMICONDUCTOR DEVICE USING THE SAME, AND
METHOD FOR CONTROLLING SELECTION RATIO OF SLURRY COMPOSITION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

* * * * *

REQUEST FOR CORRECTED FILING RECEIPT

Attached is a copy of the official filing receipt from the PTO in the above application for which
issuance of a corrected filing receipt is respectfully requested. There is an error with respect to
the following data which is incorrectly entered.

Error in

Correct data

Title

CHEMICAL-MECHANICAL-POLISHING SLURRY
COMPOSITION, METHOD FOR PLANARIZING
SURFACE OF SEMICONDUCTOR DEVICE USING
THE SAME, AND METHOD FOR CONTROLLING
SELECTION RATIO OF SLURRY COMPOSITION

Assignee

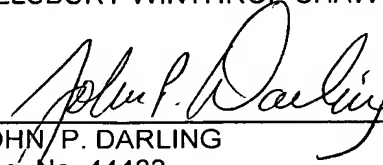
- 1) SUMCO CORPORATION
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Power of Attorney: Customer
Number

00909

Respectfully submitted,

PILLSBURY WINTHROP SHAW PITTMAN LLP

A handwritten signature in dark ink, appearing to read "John P. Darling", is written over a horizontal line.

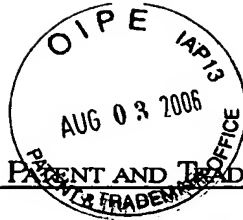
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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/540,992	06/05/2006	2812	1030	061063-0316598	10	17	1

CONFIRMATION NO. 9014

909
PILLSBURY WINTHROP SHAW PITTMAN, LLP
P.O. BOX 10500
MCLEAN, VA 22102

FILING RECEIPT



OC000000019724200

Date Mailed: 07/25/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Assignment For Published Patent Application

~~SUMITOMO MITSUBISHI SILICON CORPORATION, TOKYO, JAPAN~~

Power of Attorney: The patent practitioners associated with Customer Number ~~909~~

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16813 12/25/2003

Foreign Applications

REPUBLIC OF KOREA 10-2002-0087934 12/31/2002

If Required, Foreign Filing License Granted: 07/21/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/540,992**

Projected Publication Date: 11/02/2006

Non-Publication Request: No

Early Publication Request: No

Title

Slurry composition for chemical mechanical polishing, method for planarization of surface of semiconductor element using the same, and method for controlling selection ratio of slurry composition

Preliminary Class

438

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